

Application Note: Tantaline® Treated Rupture Disc Holders

Description

Many types of pressurized equipment are protected by rupture discs which are installed in special flange-like holders that capture and seal the discs, preventing leakage of the process fluid. To ensure proper functioning when used in corrosive process fluids the integrity of the holder as well as the disc must be retained as corrosion can cause premature failure. Tantalum is an industry accepted material used to prevent corrosive attack over time for these assemblies. Tantaline® treated holders are highly compatible and well suited for use with tantalum or graphite rupture discs found in a wide range of industrial processes. The resulting assembly provides reliable protection and extended service life of the associated equipment.

Benefits

Tantaline® treatment is a cost-effective option for achieving long term corrosion resistance and reliable sealing for the various holder types. The Chemical Vapor Deposition (CVD) process used by Tantaline produces a uniform tantalum layer that conforms to complex geometries and adheres to the substrate through diffusion bonding. The resulting smooth tantalum surface ensures proper sealing of rupture disc in the holder and prevents corrosive process fluids from adhering to the metal surface. Tantaline® treated rupture disc holders offer chemical and mechanical performance superior to those made of Hastelloy®*, titanium, or zirconium along with economical pricing and short lead-times.

Availability

Type of rupture disc holders suitable for treatment:

- √ Insert holder
- √ Bolted holder
- √ Screw type
- √ Union type
- √ Sanitary
- √ Flat seat



SUPERIOR CORROSION RESISTANCE FOR AGGRESSIVE SERVICE CONDITIONS

- √ Hydrochloric acid
- √ Sulfuric acid
- √ Acetic acid
- √ Nitric acid
- √ Sour gas (H₂S)
- √ Chlorine
- √ Many other process fluids





Use

MARKET	TYPICAL PROCESSES	TYPICAL USES
Chemical Processing	Hot acids, wet and dry chlorine, sulfur compounds, sour gases containing hydrogen sulfide (H ₂ S) compounds	Reactors, chillers, heat exchangers, safety relief valve isolation, and desulfurization units
Oil & Gas	Acid gases (CO ₂ , H ₂ S, SO ₂), ammonia (NH ₃), hydrogen cyanide (HCN), alkylation, and amine derivatives	Distillation columns, separators, LNG processing equipment, process columns, vessels, storage, and transport
Pharmaceutical	Oxidizing agents (hydrogen peroxide, bromine, chlorine)	Fermenters, bioreactors, and process vessels
Pulp and Paper	High temperature concentrated acid, sulfur gasses including H ₂ S and SO ₂ , bleaching compounds, acid slurries and acid pulps	Bleaching systems, gas recovery, discharge headers, and tanks

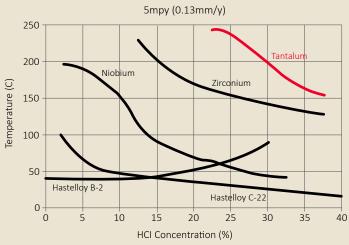
Key Technical Information

Stainless Steel, Hastelloy®*, and Inconel®** rupture disc holders are susceptible to Stress Corrosion Cracking (SCC) and pitting especially in hot acids.

Tantaline® treated rupture disc holders offers the following beneficial characteristics:

- √ Chemically resistant to SCC and pitting in many aggressive media and environments.
- √ Tantalum layer remains passivated and inert to corrosion under high temperature (>200° C) acidic conditions including concentrated HCl and H₂SO₂.****
- √ Superior corrosion resistance against wet, dry chlorine atmospheres, and other chlorinated environments.

HCI Corrosion Resistance



^{*}Hastelloy® is a registered trademark of Haynes International.

^{**}Inconel® is a trademark of Special Metals Wiggin Limited.

^{***}FJ, H. (n.d.). Properties of Tantalum for Applications in the Chemical Process Industry.